

Coating 114384

Magnetron sputtered system

HRu(45°, 1064nm) > 99.8%

HRu(45°, 1450-2000nm) > 99%

Ru(45°, 2300-4000nm) < 10%
on sapphire

important notes:

- 1) GDD not optimized
- 2) Rp(45°) ~ 2.3% Rs(45°) ~ 15.2% Ru(45°) ~ 8.8% for the uncoated sapphire rear side

fig. 1 reflection, 45°

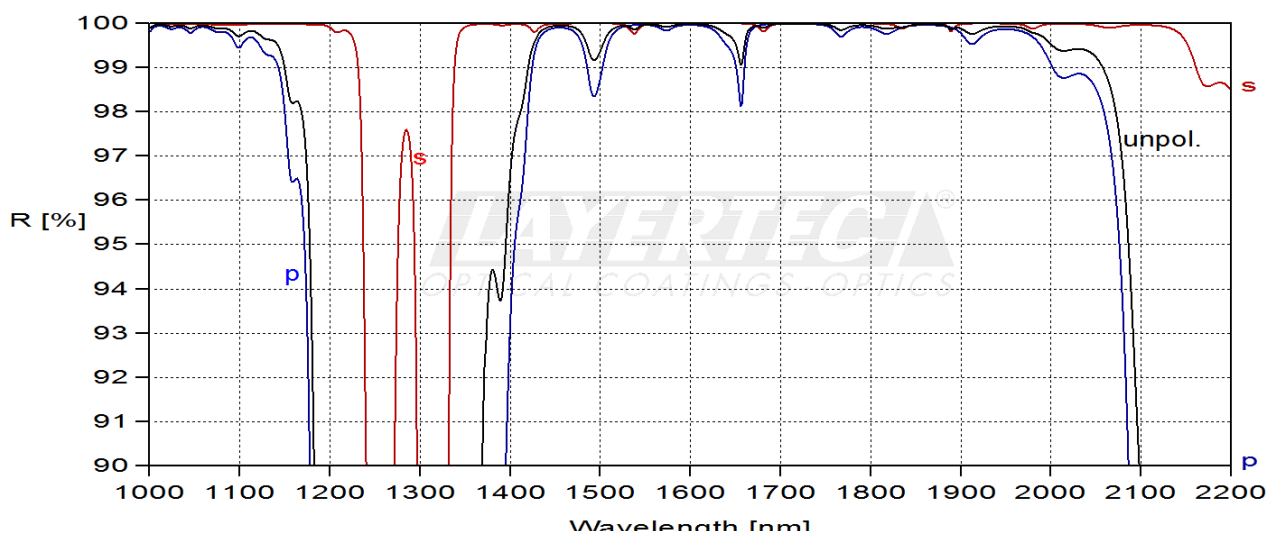


fig. 2 reflection, 45° (without substrate on rear side)

